Universal Spin Diffusion Length in Polycrystalline Graphene

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ABSTRACT: Graphene grown by chemical vapor deposition (CVD) is the most promising material for industrial-scale applications based on graphene monolayers. It also holds promise for spintronics; despite being polycrystalline, spin transport in CVD graphene has been measured over lengths up to 30 μ m, which is on par with the best measurements made in single-crystal graphene. These results suggest that grain boundaries (GBs) in CVD graphene, while impeding charge transport, may have little effect on spin transport. However, to date very little is known about the true impact of disordered networks of GBs on spin relaxation. Here, by using



first-principles simulations, we derive an effective tight-binding model of graphene GBs in the presence of spin—orbit coupling (SOC), which we then use to evaluate spin transport in realistic morphologies of polycrystalline graphene. The spin diffusion length is found to be independent of the grain size, and it is determined only by the strength of the substrate-induced SOC. This result is consistent with the D'yakonov—Perel' mechanism of spin relaxation in the diffusive regime, but we find that it also holds in the presence of quantum interference. These results clarify the role played by GBs and demonstrate that the average grain size does not dictate the upper limit for spin transport in CVD-grown graphene, a result of fundamental importance for optimizing large-scale graphene-based spintronic devices.

KEYWORDS: Graphene, CVD, polycrystalline, grain boundaries, spin relaxation, spintronics

T he growth of graphene via chemical vapor deposition (CVD) is the most promising approach for realizing industrial-scale applications of this material.^{1,2} One drawback of CVD-grown graphene is that it tends to be polycrystalline, with misoriented single-crystal domains separated by grain boundaries (GBs) consisting of arrays of five-, seven-, and occasionally eight-member carbon rings. In some specific cases the GBs can be characterized by a given periodicity, but more generally they tend to be complex meandering arrangements of these nonhexagonal rings.^{3,4} Charge transport and scanning tunneling measurements have revealed that graphene GBs serve as a significant source of charge scattering, leading to enhanced resistance^{5,6} and localization effects.^{5,7,8} Only when the graphene grains become larger than 1–10 μ m do the GBs cease to dominate the charge transport in CVD graphene.⁹

Graphene also has clear advantages for spintronic applications, owing to its low intrinsic spin-orbit coupling (SOC).^{10–12} Combined with its high electron mobility, this can lead to spin diffusion lengths as long as 30 μ m in clean exfoliated graphene-based devices (with mobility up to several 10 000 cm²/(V s)).¹³ Intriguingly, spin diffusion lengths as long as 10 μ m and spin currents measurable over channel lengths of 30 μ m have also been reported in disordered CVD graphene with much lower charge mobility.^{14,15} These measurements can be explained in two different ways: either none or very few GBs were present in the measured devices or GBs in CVD graphene, while impeding charge transport, have

little effect on spin transport and relaxation. Although the former hypothesis remains plausible, the lack of a theoretical foundation concerning spin transport in the presence of disordered networks of GBs leaves the second hypothesis open as a possibility, which could have profound consequences for the optimization of graphene-based spintronic devices.

Here we use numerical simulations to study the impact of GBs on spin transport in polycrystalline graphene. We first develop an effective tight-binding (TB) model of polycrystalline graphene in the presence of intrinsic and substrate-induced SOC, which is derived from extensive first-principles calculations. The model is based on simulations of a variety of carbon-based haeckelites and is found to be general and transferable to the complex morphologies of graphene GBs. We then use this model to perform spin transport simulations in realistic models of polycrystalline graphene, using an efficient linear-scaling methodology that gives direct access to spin relaxation and propagation. Our simulations reveal that the spin diffusion length in polycrystalline graphene is independent of grain size and depends only on the strength of the substrate-induced SOC. This result is fully consistent with the D'yakonov-Perel' mechanism of spin relaxation in the

Received:July 30, 2019Revised:September 10, 2019Published:September 18, 2019

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diffusive regime, but here it is also shown to be robust to the contributions of quantum interference induced by disorder. These findings indicate that in the presence of SOC the graphene GBs serve as scatterers of charge, but they do not play a direct role in spin relaxation. In other words, our results suggest that grain size is not a limiting factor for spin transport in CVD-grown graphene, a result of genuine relevance for the future optimization of graphene-based spin devices and architectures in the context of memory or spin logic technologies.

We first develop an effective TB model for the description of itinerant electrons in polycrystalline graphene, which is derived from fitting to first-principles simulations. The model includes the impact of electrostatic barriers and atomic disorder present at GBs, and explicitly accounts for both intrinsic and extrinsic SOC. The first-principles simulations were carried out with the all-electron FP-LAPW method as implemented in the Elk code (http://elk.sourceforge.net/). The self-consistent calculations with SOC have been carried out within the LDA approximation with a muffin tin radius of 1.316 Bohr for carbon atoms and an APW cutoff of 5.32 Bohr⁻¹. A 33 × 33 *k*-point mesh was used to sample the first Brillouin zone of pristine graphene, and equivalent *k*-point densities were used for the supercell calculations.

The starting point of our one-orbital TB model is the now well-known functional form of the second-nearest-neighbor hopping Hamiltonian of graphene. The Hamiltonian can be conveniently decomposed into a kinetic operator and a SOC operator,

$$\hat{\mathcal{H}} = \hat{\mathcal{H}}_{\rm kin} + \hat{\mathcal{H}}_{\rm SOC} \tag{1}$$

$$\hat{\mathcal{H}}_{\rm kin} = t_1 \sum_{\langle i,j \rangle} \hat{c}_{i\sigma}^{\dagger} \hat{c}_{j\sigma} + t_2 \sum_{\langle \langle i,j \rangle \rangle} \hat{c}_{i\sigma}^{\dagger} \hat{c}_{j\sigma}$$
⁽²⁾

$$\begin{aligned} \hat{\mathcal{H}}_{\text{SOC}} &= \frac{i}{3\sqrt{3}} \lambda_{\text{I}} \sum_{\langle \langle i,j \rangle \rangle} v_{ij} \hat{c}^{\dagger}_{i\sigma} (\hat{s}_{z})_{\sigma\sigma'} \hat{c}_{j\sigma'} \\ &+ \frac{2i}{3} \lambda_{\text{R}} \sum_{\langle i,j \rangle} \hat{c}^{\dagger}_{i\sigma} [\mathbf{E} \cdot (\hat{\mathbf{s}} \times \mathbf{d}_{ij})]_{\sigma\sigma'} \hat{c}_{j\sigma'} \end{aligned}$$
(3)

where $\hat{c}_{i\sigma}^{\dagger}(\hat{c}_{i\sigma})$ is the creation (annihilation) operator for the p_z orbital with spin σ at lattice site *i*, *s* is the spin Pauli matrix, **E** is the external electric field, \mathbf{d}_{ij} is the unit vector pointing from site *j* to *i* and ν_{ij} is +1 (-1) for clockwise (counterclockwise) hopping paths from site *j* to *i*. Single (double) brackets stand for summation over the nearest (second-nearest) neighboring lattice sites. In our model, we assume an exponential dependence of the t_1 and t_2 hopping parameters with respect to the intersite distance,

$$t_1 = t_1^o e^{-\beta_1(r-a)}$$
 and $t_2 = t_2^o e^{-\beta_2(r-b)}$ (4)

Here, *a* (*b*) is the equilibrium distance between the first (second) nearest atomic sites in graphene at equilibrium (*a* = 1.42 Å, $b = \sqrt{3} a = 2.46$ Å). The third term is the intrinsic SOC operator, which connects second nearest neighbor sites, and the last term is the extrinsic (Rashba) SOC operator, which arises from an external perpendicular electric field E.¹⁶ This electric field can be directly applied via a gate voltage, or it can be an effective field that arises from placing graphene on a substrate. The Rashba term connects nearest neighbor sites and linearly depends on the strength of the perpendicular electric field. The hopping integrals t_1 and t_2 , as well as the

parameters β_1 and β_2 ruling their distance dependence, were fitted together with the SOC parameters λ_I and λ_R with respect to first-principles band structure calculations of graphene at equilibrium and under isotropic strains up to 20%. As our focus is on the transport properties of low-energy itinerant electrons, the fitting has been limited to the [-1,1] eV energy window around the Fermi level. The optimized parameters are given in Table 1. The radial dependence of the hopping integral is

Table 1. Tight-Binding Parameters for Pristine Graphene Obtained from Fits to First-Principles Calculations, As Illustrated in Figure 1a-c

					$\lambda_{\rm R}$
t_1^o (eV)	β_1	t_2^o (eV)	β_2	$\lambda_{\rm I}~(\mu { m eV})$	$\left(\frac{\mu e v}{V / nm}\right)$
-2.414	1.847	-0.168	3.077	13.437	3.383

shown in Figure 1a. The perfect agreement of the model with reference band structure calculations is illustrated in Figure 1, parts b and c.

To account for the crystallographic disorder introduced by dislocations at GBs, the TB model is enriched by introducing topology-dependent renormalization factors. Within a simple ball-and-stick model, any sp² lattice can be mapped to a tiling of the plane by polygons, where each site is the shared apex of three polygons. In our case, it can be three hexagons as in graphene, or any combination of pentagons, hexagons and heptagons due to the presence of disclinations in the lattice. For the purpose of our model, we denote \mathcal{L}_i as the geometric environment of a given site i. \mathcal{L}_i can be any set of three elements out of the ensemble of considered carbon polygons $\mathcal{E} = \{5, 6, 7\}$. Similarly, \mathcal{L}_{ii} are defined as the local environment of a pair of neighboring sites i and j. If the sites are first nearest neighbors, the vector joining *i* and *j* is the shared edge of two polygons and \mathcal{L}_{ij} can be any combination of two elements of the ensemble \mathcal{E} . If the sites are second nearest neighbors, the vector joining the sites is inscribed within a polygon and \mathcal{L}_{ii} is reduced to a single element of \mathcal{E} . Finally, an extra term is added to the on-site energy of the Hamiltonian, which describes the local redistribution of charge around pentagon and heptagon carbon rings,

$$\tilde{\mathcal{H}}_{\text{loc}} = \sum_{i} \hat{c}_{i\sigma}^{\dagger} \epsilon_{i} \hat{c}_{i\sigma} \text{ with } \epsilon_{i} = \sum_{m \in \{\mathcal{L}\}} \Delta \epsilon^{m}$$
(5)

This term is crucial for the description of the resonance peaks introduced by GBs in the low-energy electronic spectrum. It also enables a geometry-dependent electrostatic alignment of the GBs with respect to the graphene grains. Note that without loss of generality we can impose the constraint $\Delta \epsilon^6 = 0$, which conveniently defines the reference energy as the charge neutrality point of pristine graphene.

To account for the local variation of aromaticity and energymomentum dispersion relation in the presence of GBs, the kinetic operator is also renormalized,

$$\tilde{\mathcal{H}}_{\rm kin} = \sum_{\langle i,j \rangle} \hat{c}^{\dagger}_{i\sigma} t_{1ij} \hat{c}_{j\sigma} + \sum_{\langle \langle i,j \rangle \rangle} \hat{c}^{\dagger}_{i\sigma} t_{2ij} \hat{c}_{j\sigma}$$

$$\tag{6}$$

with

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Figure 1. One-orbital topological TB model. Gold curves and dots correspond to first-principles results, blue curves are obtained within our topological TB model, and dashed green curves are obtained within the pristine TB model of graphene before topological renormalization. (a) Radial dependence of the hopping integrals considered in our one-orbital TB model. The green (purple) curve corresponds to the hopping between first (second) nearest neighbor lattice sites. (b) Low-energy band structure of graphene at equilibrium (left panel) and under 20% isotropic strain (right panel). (c) Band structure of graphene around the tip of the Dirac cones in the presence of SOC. The left panel shows the case with only intrinsic SOC, while the next three panels are for increasing transversal electric field (E = 1, 2.5, and 4.1 V/nm from left to right). (d) Low-energy band structure of the $H_{5,6,7}$ periodic haeckelite structure. (e) Spin splitting of the two metallic bands of the $H_{5,6,7}$ periodic haeckelite structure. (feld of 4V/nm. (f–j) Ball-and-stick representation of the five haeckelite structures included in our fitting set. Colors have been added to represent the tiling of the plane by pentagons (red), hexagons (orange) and heptagons (blue). According to the literature, 17 the structure represented in part f is named $H_{5,6,7}$.

$$t_{1ij} = t_1 \cdot \prod_{m \in \{\mathcal{L}_{ij}\}} (1 + \Delta t_1^m),$$

$$t_{2ij} = t_2 \cdot \prod_{m \in \{\mathcal{L}_{ij}\}} (1 + \Delta t_2^m).$$
(7)

We impose $\Delta t_1^6 = \Delta t_2^6 = 0$ in order to preserve the energymomentum dispersion relation of pristine graphene. The full Hamiltonian of our model now reads

$$\tilde{\mathcal{H}} = \tilde{\mathcal{H}}_{\text{loc}} + \tilde{\mathcal{H}}_{\text{kin}} + \tilde{\mathcal{H}}_{\text{SOC}}$$
(8)

The additional parameters of our topological model, $\{\Delta \epsilon^5, \Delta \epsilon^7, \Delta t_1^5, \Delta t_1^7, \Delta t_2^5, \Delta t_2^7\}$, have been fitted against a set of firstprinciples band structures corresponding to periodic carbon sp² systems containing five-, six-, and seven-membered rings. The structures used for the fitting of our model, known as haeckelites,¹⁷ are illustrated in Figure 1f–j. These haeckelite structures have been created via the incorporation of disclinations into 2 × 2 and 3 × 3 graphene supercells. The considered geometries have been fully relaxed with respect to both atomic and cell degrees of freedom. The topological parameters obtained by fitting the low-energy band structures are given in Table 2.

We note that the renormalization of the nearest neighbor hopping integral is very weak. This directly reflects the sp² character of the fitting set, and additional benchmarks revealed Table 2. Tight-Binding Parameters Describing the Renormalization of Charge Doping and Energy Dispersion at Graphene GBs, Obtained from First-Principles Simulations of Carbon Haeckelite Structures, As Illustrated in Figure 1d-j

$\Delta\epsilon^5~(\mathrm{eV})$	$\Delta\epsilon^7~(\mathrm{eV})$	Δt_1^5	Δt_1^7	Δt_2^5	Δt_2^7
0.4988	-0.497	0.0005	0.0414	-0.04	-0.4095

that these renormalization factors contribute only marginally to the improved description of sp² carbon structures. The main contribution to the success of the model comes from the geometry-dependent renormalization of the onsite energies. Parts d and e of Figure 1 illustrate the improved description of itinerant electrons due to the renormalization. While Δe^5 and Δe^7 improve the description of the low-energy bands of the haeckelite structures, as shown in Figure 1d, they are also instrumental in obtaining a qualitative and quantitative description of the spin splitting induced by SOC in the presence of a transverse electric field, as shown in Figure 1e.

While this model has been developed based on simulations of haeckelite structures, it must also be transferrable and applicable to the variety of GB structures that can be present in polycrystalline graphene. We therefore test our model on two prototypical GBs, associated with the (2,1)l(1,2) and (5,0)l(3,3) interfaces. These correspond to a conducting type I GB and a type II GB with a transport gap, respectively, as classified

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Figure 2. Electronic structure of prototypical periodic GBs. Ball-and-stick representations of the (2,1)|(1,2) and (5,0)|(3,3) GBs are shown in panels a and d, respectively. Colors have been added to visualize the pentagons (red) and heptagons (blue). Yellow and green are used to depict the hexagonal carbon rings of the two separate graphene domains. (b) Low-energy band structure of the (2,1)|(1,2) GB. (c) Spin splitting of the two metallic bands of the (2,1)|(1,2) GB under a transverse electric field of 4 V/nm, with linear (upper panel) and logarithmic (lower panel) vertical axis scale. Panels e and f are the same as panels b and c for the (5,0)|(3,3) GB. Gold curves are first-principles results, blue curves are the renormalized TB model, and dashed green curves are the TB model of pristine graphene without renormalization due to GBs.

by Yazyev.¹⁸ The optimized geometries as well as the computed band structures and the spin splitting of the lowenergy bands are shown in Figure 2. As the computational cells are larger in these cases, we turned to numerical atomic orbitals (NAOs) to compute the reference band structures.

The self-consistent calculations have been performed with the OpenMX package, $^{19-21}$ relying on a double- ζ polarized

basis set for the expansion of the eigenstates. The first Brillouin zones of the (2,1)|(1,2) and (5,0)|(3,3) GBs were sampled with k-point grids of 16×3 and 8×3 , respectively. As shown in Figure 2, the topological model enables an accurate description of the electronic structure of the two prototypical GBs. Additionally, the renormalization is crucial for obtaining a qualitative and a quantitative description of the SOC-induced

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spin splitting of the low-energy bands, as the TB model of pristine graphene (eq 1) underestimates this splitting by orders of magnitude (see the dashed green curves in Figure 2c,f). Finally, we note that our model does not capture the effect of vacancies or imperfect bonding configurations, both of which may be present in CVD-grown graphene. However, these account for only ~0.1% of the atoms in our MD-generated polycrystalline samples, and thus we do not expect them to have a significant impact on our results. Furthermore, progress in fabrication techniques now allows for very clean large-area polycrystalline graphene that is free from cracks and other strong lattice imperfections.²

With an accurate TB model in hand, we now turn to simulations of charge and spin transport in polycrystalline graphene. The polycrystalline samples have been created via molecular dynamics simulations that mimic the CVD growth process.^{22,23} We use three samples that were previously used in ref 23, with average grain diameters of 14.8, 20.9, and 29.7 nm. For this study we have also created two additional samples with average grain diameters of 14.9 and 21 nm. The 20.9 nm sample is shown in Figure 3a, where the magenta regions are the pristine graphene grains and the black areas depict the nonhexagonal rings in the structure. The inset is a zoom-in of one graphene GB, showing a disordered array of pentagons and heptagons between two misoriented grains.

To study charge and spin transport in the polycrystalline samples, we employ a real-space wave packet propagation method that has been used to study charge and spin transport in a wide variety of disordered systems.^{24–26} At time t = 0, we define

$$|\psi(0)\rangle = \frac{1}{\sqrt{N}} \sum_{n=1}^{N} e^{i\xi_n} |n\rangle$$
(9)

where $\xi_n \in [0,2\pi)$ is a random phase associated with each atomic site $|n\rangle$ in the polycrystalline sample, $|n\rangle$ is an $N \times 1$ vector with a 1 at row *n* and zeros elsewhere, and *N* is the total number of atoms in the sample. This random phase state is then spin-polarized along the *z*-axis according to

$$|\psi_{\uparrow}(0)\rangle = \begin{bmatrix} I_N \\ 0 \end{bmatrix} |\psi(0)\rangle \tag{10}$$

where I_N is the $N \times N$ identity matrix. We let this wave packet evolve in time and we calculate its mean square displacement $\Delta X^2(E_{\rm F}, t)$ and its out-of-plane spin polarization $s_z(E_{\rm F}, t)$ as a function of Fermi energy and time,

$$\Delta X^{2}(E_{\rm F}, t) = \frac{\langle \psi_{\uparrow}^{\rm X}(t) | \delta(E_{\rm F} - \tilde{\mathcal{H}}) | \psi_{\uparrow}^{\rm X}(t) \rangle}{\langle \psi_{\uparrow}(0) | \delta(E_{\rm F} - \tilde{\mathcal{H}}) | \psi_{\uparrow}(0) \rangle}$$
(11)

$$s_{z}(E_{\rm F}, t) = \operatorname{Re}\left\{\frac{\langle\psi_{\uparrow}(t)|\delta(E_{\rm F} - \tilde{\mathcal{H}})\sigma_{z}|\psi_{\uparrow}(t)\rangle}{\langle\psi_{\uparrow}(0)|\delta(E_{\rm F} - \tilde{\mathcal{H}})|\psi_{\uparrow}(0)\rangle}\right\}$$
(12)

where $|\psi_{\uparrow}^{X}(t)\rangle = [\hat{X}, \hat{U}(t)] | \psi_{\uparrow}(0)\rangle$, \hat{X} is the position operator, $\hat{U}(t) = \exp(-i\tilde{\mathcal{H}}t/\hbar)$ is the time evolution operator, $|\psi_{\uparrow}(t)\rangle = \hat{U}(t) | \psi_{\uparrow}(0)\rangle$, and σ_{z} is the Pauli matrix for spin along the *z*-axis. The time evolution operator and the energy projection operator $\delta(E_{\rm F} - \tilde{\mathcal{H}})$ are both expanded in a numerically efficient way using Chebyshev polynomials. From the mean square displacement, we calculate the diffusion coefficient D,



Figure 3. (a) Structure of the polycrystalline graphene sample with 20.9 nm average grain diameter. The inset shows a zoom-in of one of the graphene GBs. (b) Time-dependent conductivity for a Rashba SOC strength $\lambda_{\rm R}|\mathbf{E}| = 100 \ \mu \rm eV$ at $E_{\rm F} = 0.2 \ \rm eV$, corresponding to a carrier density of $n \approx 5 \times 10^{12} \ \rm cm^{-2}$. The inset shows the conductivity as a function of propagation length. The blue solid line is the numerical result, and the red dashed line is obtained from weak localization theory. (c) Corresponding out-of-plane spin polarization. The solid line is the numerical result, and the dashed line is the expected decay assuming DP spin relaxation in the diffusive regime of transport.

the electrical conductivity σ_{i} and the momentum relaxation time $\tau_{_{\mathrm{D}}}$

$$D(E_{\rm F}, t) = \frac{1}{2} \frac{\rm d}{{\rm d}t} \Delta X^2(E_{\rm F}, t)$$
(13)

$$\sigma(E_{\rm F}, t) = {\rm e}^2 \rho(E_{\rm F}) D(E_{\rm F}, t)$$
(14)

$$\tau_{\rm p}(E_{\rm F}) = \frac{2D_{\rm max}(E_{\rm F})}{v_{\rm F}^2}$$
(15)

where $\rho(E_{\rm F}) = 2\langle \psi_{\uparrow}(0)|\delta(E_{\rm F} - \tilde{\mathcal{H}})|\psi_{\uparrow}(0)\rangle$ is the density of states, $\nu_{\rm F}$ is the Fermi velocity of graphene, and $D_{\rm max}(E_{\rm F}) = \max\{D(E_{\rm F}, t)\}.$

We simulated charge and spin transport in the five different polycrystalline samples mentioned above, using both the pristine graphene TB model of eq 1 and the renormalized GB model of eq 8, for Rashba SOC strengths of $\lambda_{\rm R}|{\rm E}|$ = 12.5, 25, 50, and 100 μ eV and 1 meV. The values in the lower μ eV range are typical of those seen in graphene on SiO₂ or hBN substrates,²⁷ while the range [100 μ eV, 1 meV] corresponds to what is seen when graphene is placed in contact with a transition metal dichalcogenide or a topological insulator.^{28,29}

Typical results are shown in parts b and c of Figure 3 for the 20.9 nm sample with the full GB model, $\lambda_{\rm R}$ |E| = 100 μ eV, and $E_{\rm F} = 0.2$ eV, corresponding to a carrier density of $n \approx 5 \times 10^{12}$ cm⁻². Figure 3b shows the electrical conductivity σ as a function of time. At short times σ increases linearly, indicative of the ballistic regime of transport, and saturates to a maximum value as scattering off the GBs forces transport into the diffusive regime. At longer times, quantum interference leads to localized behavior, as indicated by the decay of σ with time. In the inset, we plot σ as a function of the propagation length $L \equiv 2\sqrt{\Delta X^2}$. The blue solid line shows the numerical results and the red dashed line is the decay expected from weak localization (WL) theory,³⁰ $\sigma(L) = \sigma_{\rm sc} - (G_0/\pi) \ln (L/l_{\rm e})$, where $\sigma_{\rm sc} = \max{\{\sigma(t)\}}$ is the semiclassical conductivity, $G_0 =$

 $2e^2/h$ is the quantum of conductance, and $l_e = \tau_p v_F$ is the mean free path. The reasonable agreement of WL theory to the numerical results, without any fitting parameters, indicates that at longer times the charge transport in the polycrystalline samples is in the weakly localized regime. This trend appears to break down for L > 200 nm, which could be due to periodicity effects, as the size of the periodic polycrystalline sample is 180 × 180 nm.

The solid line in Figure 3c shows that the out-of-plane spin polarization s_z decays with time, indicating spin relaxation induced by scattering off the graphene GBs. The dashed line shows the expected decay assuming the D'yakonov–Perel' (DP) mechanism,³¹ which is typically the dominant mechanism of spin relaxation in two-dimensional electron systems with Rashba SOC.³² This decay is given by $s_z(t) = \exp(-t/\tau_s)$, where $\tau_s = 1/(\Omega_R^2 \tau_p)$ is the spin lifetime, $\Omega_R = 2\lambda_R |\text{El}/\hbar$ is the spin precession frequency, and τ_p is determined numerically from eq 15. At short times, the decay of s_z follows the DP relation, but at longer times, there is a clear slowing down of spin relaxation. This coincides with the onset of localization, the result being that one cannot define a unique spin lifetime in this system.

To obtain a global picture of spin transport and relaxation in polycrystalline graphene, in Figure 4 we plot all our simulation results. Figure 4 shows the conductivity as a function of time, where the dashed lines are for the pristine graphene TB model of eq 1 and the solid lines are for the renormalized GB model of eq 8. Comparing the solid and dashed lines reveals that the redistribution of the charge around the GBs leads to enhanced scattering, reducing τ_p by an average of ~10%. Despite these differences in scattering strength, localization is clearly present in all cases. For each sample the six curves corresponding to different values of λ_R |E| lie nearly on top of each other, as the presence of SOC does not significantly affect the charge transport.

Figure 4b shows the out-of-plane spin polarization s_z as a function of time. In this figure a few trends can be observed. First, the rate of spin relaxation increases with Rashba SOC strength and with grain size (and thus with τ_p), which is qualitatively similar to the behavior expected from DP spin relaxation. Second, the spin relaxation is faster for the pristine



Figure 4. (a) Time-dependent conductivity for all simulations run in this work. Each set of colors corresponds to increasing grain sizes of 14.8, 14.9, 20.9, 21, and 29.7 nm. The dashed lines are for the pristine graphene TB model of eq 1 and solid lines are for the renormalized GB model of eq 8. (b) Time-dependent spin polarization for all simulations, where each color corresponds to increasing Rashba SOC strength of $\lambda_{\rm R}$ [E] = 12.5, 25, 50, and 100 μ eV and 1 meV. The dashed/ solid lines have the same meaning as in panel a. (c) Spin polarization as a function of mean square displacement. Each color corresponds to a different Rashba SOC strength. Open squares (crosses) are numerical results for the pristine (renormalized GB) model of graphene. Solid lines correspond to eq 16, and dashed lines include the effect of Elliott–Yafet spin relaxation. The inset is a zoom to better show the case of $\lambda_{\rm R}$ [E] = 1 meV.

graphene model compared to the full GB model. This is also consistent with DP theory, as weaker scattering leads to faster spin relaxation. However, as discussed above, the rate of spin relaxation is not constant and in no case is it possible to identify a unique spin lifetime in any of the simulated systems.

However, it is possible to define a unique spin transport length in these polycrystalline graphene systems. The theory of DP spin relaxation was developed for transport in the diffusive regime, and in this regime the mean square displacement of charge carriers grows linearly in time, $\Delta X^2 = 2Dt$. Using the definition of τ_p in eq 15 and plugging both into the theory of DP spin relaxation gives the spin polarization versus the propagation length

$$s_z(L) = \exp\left(-\Delta X^2 \cdot \left(\frac{\Omega_R}{\nu_F}\right)^2\right)$$
(16)

This expression indicates that the spin propagation is independent of disorder. This is a well-known consequence of DP spin relaxation and can be rationalized as follows.³² In the diffusive regime of transport the spin diffusion length is defined as $L_s \equiv \sqrt{D\tau_s}$. Because $D \propto \tau_p$ and $\tau_s \propto 1/\tau_p$, we have a disorder-independent spin diffusion length $L_s = v_F/\Omega_R$.

Our simulations are well-described by this scaling behavior, as shown in Figure 4, where the spin polarization s_z is plotted as a function of the mean square displacement ΔX^2 . The symbols are the numerical results, and one can see that they all collapse into a single universal decay that depends only on the strength of the Rashba SOC. The solid lines correspond to eq 16, indicating that in our simulations the spin relaxation is dominated entirely by the DP mechanism, including for longer times when weak localization is prevalent.

To summarize, we have used first-principles calculations to derive a tight-binding model for graphene that includes grain boundaries in the presence of spin—orbit coupling. We found that both the electronic and the spin properties of the GBs are captured by accounting for the redistribution of charge around the pentagons and heptagons that lie at the interface between misoriented graphene grains. We then used this model to study charge and spin transport in realistic models of polycrystalline graphene. In the presence of Rashba and intrinsic SOC, we found that spin relaxation is determined entirely by the D'yakonov—Perel' mechanism. Within this mechanism the spin diffusion length is independent of disorder and depends only on the strength of the Rashba SOC. Our numerical simulations confirm this behavior, both in the diffusive and in the weakly localized regimes of transport.

One interesting result of our simulations is that the disorderindependence of the spin diffusion length extends to the weakly localized regime of transport. This effect has been studied analytically, and it was found that in the presence of weak localization the diffusion coefficient and the spin relaxation rate are both renormalized by the same factor, meaning that $L_s \equiv \sqrt{D\tau_s}$ remains constant.³³ It has also been suggested that the independence of L_b on disorder should extend to the strongly localized or insulating regime of transport.³⁴ Our simulations are a direct confirmation of the universality of L_s in the diffusive and weakly localized regimes, but further numerical simulations with stronger disorder would be needed to confirm this behavior in the insulating regime.

In addition to the DP mechanism, it has been predicted that in the presence of Rashba SOC the out-of-plane spin can also be relaxed by the Elliott-Yafet (EY) mechanism.35 In this mechanism each scattering event has a finite probability to flip the spin, and the spin lifetime is given by $\tau_s = (E_F/(2\lambda_R|E|))^2 \tau_p$. The dashed lines in Figure 4 show the expected spin relaxation in the presence of both DP and EY mechanisms assuming τ_{p} = 6.5 fs, corresponding to the average τ_p of the polycrystalline samples. This clearly gives a faster spin relaxation than the numerical results, indicating the EY spin relaxation is either nonexistent in our simulations or much weaker than predicted. In the original prediction of EY spin relaxation in graphene, the quadratic scaling of τ_s with E_F was a consequence of the Diraclike linear dispersion of the electrons. However, this linear dispersion relation does not necessarily describe the transport of electrons in graphene GBs, and thus the above expression for EY spin relaxation may not be appropriate for polycrystalline graphene.

The most consequential result of this work is that in the presence of Rashba and intrinsic SOC, the spin diffusion length in polycrystalline graphene is independent of grain size, $L_s = v_F/\Omega_R$. This means that for a Rashba SOC strength of 50 μ eV (5 μ eV), the spin diffusion length will be $L_s \approx 5 \,\mu$ m (50 μ m) whether the graphene grains are 10 nm or 10 μ m in diameter. Thus, for spintronics applications, single-domain graphene may not be a necessity and focus can be placed on eliminating other sources of spin relaxation, such as magnetic impurities.³⁶ In general, these results bode well for scalable CVD-grown graphene as an efficient transporter of spins in future spintronic applications.

Finally, we point out that this study only considers uniform SOC, but other sources of spin relaxation could be present in CVD graphene. For example, out-of-plane corrugation induces local variations in SOC which can relax spin. Theoretical studies of single-crystal graphene concluded that the impact of corrugations is weak, with $L_s > 100 \ \mu m.^{37}$ Meanwhile, a variety of AFM studies were unable to identify any height variation arising from graphene GBs,^{5,38-40} and if present it is limited to <0.3 Å.41 It is unclear whether localized corrugations of this height would contribute to spin relaxation in CVD graphene, and this would therefore be an intriguing future direction of research. Measurements of CVD graphene suggest that spin relaxation at GBs is not very strong,^{14,15} but in the worst-case scenario we would expect corrugations at the GBs to limit $L_{\rm s}$ to the graphene grain size, $L_{\rm s} \sim 10 \ \mu {\rm m}$. Beyond corrugations, historically it is believed that spin transport in graphene has been limited by paramagnetic impurities and contact-induced dephasing. In early measurements these effects limited spin lifetimes to hundreds of picoseconds and $L_{\rm s} \sim 1 \ \mu {\rm m.}^4$ Improvements in these areas now permit the measurement of $L_{\rm s}$ > 10 μ m, and as high as 30 μ m in the best nonlocal measurements to date.¹³ Altogether, the spin diffusion length arising from DP spin relaxation is therefore on par with these other sources of spin relaxation, and it may even be the dominant mechanism in the highest-quality CVD samples currently being produced.

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Notes

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ACKNOWLEDGMENTS

All authors acknowledge support from the European Union Horizon 2020 Programme under Grant Agreement Nos. 696656 and 785219 (Graphene Flagship Core 1 and Core 2). ICN2 is supported by the Severo Ochoa program from Spanish MINECO (Grant No. SEV-2017-0706) and funded by the CERCA Programme/Generalitat de Catalunya. S.M.-M.D and J.-C.C. acknowledge the National Fund for Scientific Research of Belgium [F.R.S.- FNRS] and the Fédération Wallonie-Bruxelles through the "3D nanoarchitecturing of 2D crystals" project (ARC - 16/21-077) for financial support. Computational resources were provided by the supercomputing facilities of the Université catholique de Louvain (CISM/ UCL) and the "Consortium des Équipements de Calcul Intensif" en Fédération Wallonie-Bruxelles (CECI).

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